IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Fumitaka Sugaya

Serial No.: 09/387,857

:

Filed: September 1, 1999 : Examiner: C. Novacek

For: A SEMICONDUCTOR

DEVICE AND A METHOD

OF MANUFACTURING THE

SAME

Atty Docket: 21776/0039

Art Unit: 2822

## RESPONSE AND AMENDMENT UNDER 37 CFR § 1.111

Commissioner for Patents Washington, D.C. 20231

Sir:

In response to the Office Action dated September 11, 2001, please amend the above-identified application as follows:

## IN THE TITLE

Please amend the title to read --A METHOD FOR FABRICATING A
SEMICONDUCTOR STORAGE DEVICE HAVING AN INCREASED DIELECTRIC
FILM AREA--

## IN THE SPECIFICATION

Kindly amend the specification as follows:

On page 2, prior to "BACKGROUND OF THE INVENTION", insert the following sentence: